

Form PTO-1449



INFORMATION DISCLOSURE CITATION
IN AN APPLICATION
(Use separate sheets if necessary)

Docket Number (Continued)

TSMC-02-622

Application Number

10/718,877

Applicant

Shih-Wei Wang et al.

Filing Date

11/21/03

Group Art Unit

U. S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILED DATE IF APPROPRIATE
KR	6417046	7/9/02	Ho et al.	438	257	5/5/00
	6184088	2/6/01	Kurooka et al.	438	264	2/25/99
	6268624	7/31/01	Sobek et al.	257	321	7/31/99
	5966606	10/12/99	Ono	438	303	5/14/97
KR	5827769	10/27/98	Aminzadeh et al.	438	305	11/20/96

FOREIGN PATENT DOCUMENTS

	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						YES	NO

OTHER DOCUMENTS (Including Author, Title, Date, Portion of Pages, Etc.)

EXAMINER

DATE CONSIDERED

4/7/05

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.